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Author(s) V.V. Krzhizhanovskaya

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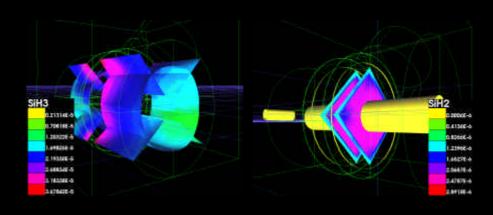
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A Virtual Reactor for Simulation of Plasma Enhanced Chemical Vapor Deposition



Valeria Krzhizhanovskaya

Invitation

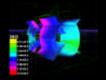
to attend the public defense of my Ph.D. thesis

A Virtual Reactor for Simulation of Plasma Enhanced Chemical Vapor Deposition

Friday, 20 June 2008 12:00

Agnietenkapel

Oudezijds Voorburgwal 231 Amsterdam



There will be a reception after the ceremony

Valeria Krzhizhanovskaya valeria@science.uva.nl